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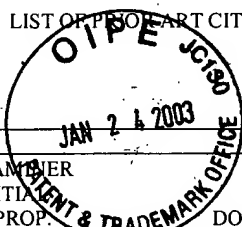
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LIST OF PRIOR ART CITED BY APPLICANT

Applicant(s): Alexei Pilipetskii et al.

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Group: 2633

EXAMINER
INITIALS
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U.S. PATENT DOCUMENTS

| EXAMINER INITIALS APPROPRIATE | DOCUMENT NUMBER | DATE | NAME | CLASS | SUB | FILING DATE |
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| | AA | | | | | |
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FOREIGN PATENT DOCUMENTS

| | DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUBCLASS | TRANSLATION YES NO |
|----|------------------|---------|---------|-------|----------|-----------------------|
| sk | BA 1 0 3 5 6 7 1 | 9/13/00 | Europe | H04B | 10/18 | |
| sk | BB 2 7 9 0 6 2 5 | 9/8/00 | France | H04B | 10/12 | X* |
| | BC | | | | | |
| | BD | | | | | |
| | BE | | | | | |

(OTHER PRIOR ART, INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)

CA M. Murakami et al., "Long-Haul WDM Transmission Using Higher Order Fiber Dispersion Management", Journal of Lightwave Technology, IEEE. New York, US, vol. 18, no. 9, September 2000, pages 1197-1204.

CB T. Tsuritani et al., "Performance Comparison between SCDCF-based System and RDF-based System in Slope-compensating Transoceanic WDM Transmission", Electronic Letters, IEE Stevenage, GB, vol. 36, no. 5, March 2, 2000, pages 447-448.

CC M. E. Marhic et al., "Optimizing the Location of Dispersion Compensators in Periodically Amplified Fiber Links in the Presence of Third-Order Nonlinear Effects", IEEE Photonics Technology Letters, IEEE Inc., New York, US, vol. 8, no. 1, 1996, pages 145-147.

EXAMINER

DATE CONSIDERED

Shi Ki Li

11/6/2003

EXAMINER: Initial if reference is considered, whether or not citation is in conformance with MPEP 609: Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to application.

* See enclosed copy of U.S. equivalent, U.S. Patent No. 6,324,317